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<http://www.springer.com/978-3-211-99310-1>

Chemical Solution Deposition of Functional Oxide Thin  
Films

Schneller, T.; Waser, R.; Kosec, M.; Payne, D. (Eds.)

2013, XVII, 796 p. 390 illus., 133 illus. in color.,

Hardcover

ISBN: 978-3-211-99310-1